



Erratum: “Interlayer coupling in ferromagnetic epitaxial Fe₃Si/FeSi₂ superlattices” [Appl. Phys. Lett. 89, 253110 (2006)]

T. Yoshitake, T. Ogawa, D. Nakagauchi, D. Hara, M. Itakura, N. Kuwano, Y. Tomokiyo, K. Takeda, T. Kajiwara, M. Ohashi, G. Oomi, and K. Nagayama

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T. Yoshitake, T. Ogawa, D. Nakagauchi, D. Hara, M. Itakura, N. Kuwano, and Y. Tomokiyo
*Department of Applied Science for Electronics and Materials, Kyushu University, 6-1 Kasuga
816-8580, Japan*

K. Takeda and T. Kajiwara
*Department of Electrical Engineering, Fukuoka Institute of Technology, 3-30-1 Wajiro-Higashi, Fukuoka
811-0295, Japan*

M. Ohashi and G. Oomi
Department of Physics, Kyushu University, 4-2-1 Ropponmatsu, Fukuoka 810-8560, Japan

K. Nagayama
Department of Aeronautics, Kyushu University, 744 Motoooka, Fukuoka 819-0395, Japan

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The electric conductivity of the FeSi₂ single-layer film was wrongly estimated as 1.2×10^3 S/cm. Therefore, the term “ 1.2×10^3 S/cm” in the last line on page 253110-1 should be modified as “ 4.0×10^2 S/cm.” Due to this correction, the sentence, “...is within an order of magnitude...” in the second paragraph on page 253110-1 should be modified as “...is approximately an order of magnitude...”

In the second paragraph on page 253110-2, the term “Fe₃Si-011” should be modified as “Fe₃Si-111.”

These corrections do not affect any other part of the article and the conclusions.